

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Shimbori, H.  
Appl. No. : 10/561,760  
Filed : December 21, 2005  
For : RESIN FOR POSITIVE RESIST  
COMPOSITION, AND POSITIVE  
RESIST COMPOSITION USING  
THE SAME, LAMINATE AND  
METHOD FOR FORMING  
RESIST PATTERN  
Examiner : Lee, Sin J.  
Group Art Unit : 1752

AMENDMENT AND RESPONSE TO FINAL OFFICE ACTION

**Mail Stop AF**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the final Office Action mailed **March 18, 2008**, please consider the following amendments and remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 5 of this paper.